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COST IN U.S. DOLLARS  
  
FULL ESTIMATED COST

SINCE FILE ENTRY 0.21	TOTAL SESSION 0.21
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FILE 'EPFULL' ENTERED AT 11:18:36 ON 16 MAR 2005  
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FILE 'USPATFULL' ENTERED AT 11:18:36 ON 16 MAR 2005  
CA INDEXING COPYRIGHT (C) 2005 AMERICAN CHEMICAL SOCIETY (ACS)

FILE 'USPAT2' ENTERED AT 11:18:36 ON 16 MAR 2005  
CA INDEXING COPYRIGHT (C) 2005 AMERICAN CHEMICAL SOCIETY (ACS)

=> s low molecular weight polyphenylene ether#  
4 FILES SEARCHED...

## L2 81 L1 AND VISCOSITY

### L3 15 L2 AND MOLECULAR WEIGHT DISTRIBUTION

L4 12 L3 AND GLASS TRANSITION TEMPERATURE

L5 O L4 AND MEAN PARTICLE SIZE#

=> 8 FILES SEARCHED...  
3 FILES SEARCHED...  
4 FILES SEARCHED...  
6 FILES SEARCHED...

L6 9 L4 AND (2,6-DIMETHYLPHENOL OR 2,6-DIMETHYL PHENOL)

=> s 16 and oxygen containing gas and catalyst#  
L7 0 L6 AND OXYGEN CONTAINING GAS AND CATALYST#

=> d 16 1-9

L6 ANSWER 1 OF 9 EPFULL COPYRIGHT 2005 EPO/FIZ KA on STN

AN 2003:138408 EPFULL

DUPD 20040915 DUPW 200438

**TIEN CONDUCTIVE MASTER BATCH AND CONDUCTIVE RESIN COMPOSITION**

**TIFR MELANGE MAITRE CONDUCTEUR ET COMPOSITION DE RESINE CONDUCTRICE.**

IN 3TERADA, Kazunori, Asahi-Kasei-Kaz

Sodegaura-shi, Chiba 299-0261, JP;

NODA, Kazuya, Asahi-Kasei-Shatake

PA Asahi Kasei Kabushiki Kaisha, 2-6, Dojimahama 1-chome, Kita-ku,  
Osaka-shi, Osaka 530-8205, JP  
PAN 219576  
AG Weber, Thomas, Dr.Dipl.-Chem., et al, Patentanwaelte von  
Kreisler-Selting-Werner, Postfach 10 22 41, 50462 Koeln, DE  
AGN 75091  
LAF Japanese  
LA English  
LAP English  
TL English; French  
DT Patent  
PIT WOAI International application published with search report  
PI WO 2004060980 A1 20040722  
DS AT BE BG CH CY CZ DE DK EE ES FI FR GB GR HU IE IT LI LU MC NL PT RO SE  
SI SK TR  
AI EP 2003-746150 A 20030717  
WO 2003-JP9104 A 20030717  
PRAI JP 2002-377067 A 20021226  
JP 2003-153159 A 20030529  
IC.VER 7  
ICM C08J003-22  
ICS C08L071-02; C08L077-00; C08K003-04  
  
AN 2003:138408 EPFULL  
DUPD 20041208 DUPW 200450  
TIEN CONDUCTIVE MASTER BATCH AND CONDUCTIVE RESIN COMPOSITION.  
TIFR MELANGE MAITRE CONDUCTEUR ET COMPOSITION DE RESINE CONDUCTRICE.  
TIDE LEITFAeHIGE VORMISCHUNG UND LEITFAeHIGE HARZZUSAMMENSETZUNG.  
IN 3TERADA, Kazunori, Asahi-Kasei-Kazusa-Ryo 306, 3-10-1, Fukuodai,  
Sodegaura-shi, Chiba 299-0261, JP;  
NODA, Kazuya, Asahi-Kasei-Shataku 5-22, 3-10-1, Fukuodai,  
Sodegaura-shi, Chiba 299-0261, JP  
PA Asahi Kasei Chemicals Corporation, 1-2, Yuraku-cho 1-chome, Chiyoda-ku,  
Tokyo 100-8440, JP  
PAN 4659480  
AG Weber, Thomas, Dr.Dipl.-Chem., et al, Patentanwaelte von  
Kreisler-Selting-Werner, Postfach 10 22 41, 50462 Koeln, DE  
AGN 75091  
LAF Japanese  
LA English  
LAP English  
TL German; English; French  
DT Patent  
PIT EPA1 Application published with search report  
PI EP 1473317 A1 20041103  
WO 2004060980 20040722  
DS AT BE BG CH CY CZ DE DK EE ES FI FR GB GR HU IE IT LI LU MC NL PT RO SE  
SI SK TR  
AI EP 2003-746150 A 20030717  
WO 2003-JP9104 A 20030717  
PRAI JP 2002-377006 A 20021226  
JP 2003-153159 A 20030529  
IC.VER 7  
ICM C08J003-22  
ICS C08L071-02; C08L077-00; C08K003-04; C08L077-06; C08L071-12; C08L077-02  
  
L6 ANSWER 2 OF 9 PCTFULL COPYRIGHT 2005 Univentio on STN  
AN 1996016123 PCTFULL ED 20020514  
TIEN POLYAMIDE RESIN COMPOSITION  
TIFR COMPOSITION DE RESINE POLYAMIDE  
IN NAKAHASHI, Jun-ichi;  
HORIO, Mitsuhiro;  
YOSHIDA, Kazuo  
PA ASAHI KASEI KOGYO KABUSHIKI KAISHA;  
NAKAHASHI, Jun-ichi;  
HORIO, Mitsuhiro;  
YOSHIDA, Kazuo  
LA English

DT Patent  
PI WO 9616123 A1 19960530  
DS W: CN DE GB NL US  
AI WO 1994-JP1947 A 19941118  
ICM C08L077-00  
ICS C08L071:12; C08L077:00; C08L071:12; C08L025:08; C08L051:06

L6 ANSWER 3 OF 9 USPATFULL on STN  
AN 2004:185175 USPATFULL  
TI Thermoplastic resin composition and molded articles  
IN Nakagawa, Matsuyoshi, Sodegaura, JAPAN  
Miyoshi, Takaaki, Kimitsu, JAPAN  
Noda, Kazuya, Chigasaki, JAPAN  
PI US 2004143061 A1 20040722  
AI US 2003-478413 A1 20031121 (10)  
WO 2002-JP4913 20020521  
PRAI JP 2001-156000 20010524  
JP 2002-30550 20020207

DT Utility  
FS APPLICATION  
LN.CNT 1093  
INCL INCLM: 525/088.000  
INCLS: 525/089.000  
NCL NCLM: 525/088.000  
NCLS: 525/089.000  
IC [7]  
ICM: C08L053-00

CAS INDEXING IS AVAILABLE FOR THIS PATENT.

L6 ANSWER 4 OF 9 USPATFULL on STN  
AN 2004:108327 USPATFULL  
TI CONDUCTIVE MASTERBATCH AND CONDUCTIVE RESIN COMPOSITION  
IN TERADA, Kazunori, Asahi-Kasei-Kazusa-Ryo 306, 3-10-1, Fukuodai,  
Sodegaura-shi, Chiba-ken, JAPAN 299-0261  
NODA, Kazuya, Asahi-Kasei-Shataku 5-22, 3-10-1, Fukuodai, Sodegaura-shi,  
Chiba-ken, JAPAN 299-0261  
PA ASAHI KASEI KABUSHIKI KAISHA, Osaka, JAPAN, 530-8205 (non-U.S.  
individual)

PI US 2004082729 A1 20040429  
AI US 2003-620557 A1 20030717 (10)  
PRAI JP 2002-377006 20021226  
JP 2003-153159 20030529

DT Utility  
FS APPLICATION  
LN.CNT 1876  
INCL INCLM: 525/390.000  
INCLS: 525/397.000; 528/335.000  
NCL NCLM: 525/390.000  
NCLS: 525/397.000; 528/335.000  
IC [7]  
ICM: C08G069-26  
ICS: C08G065-48; C08L071-12

CAS INDEXING IS AVAILABLE FOR THIS PATENT.

L6 ANSWER 5 OF 9 USPATFULL on STN  
AN 2003:201531 USPATFULL  
TI Electrically conductive resin composition and production process thereof  
IN Miyoshi, Takaaki, Kimitsu, JAPAN  
Hashimoto, Kazuhiko, Sodegaura, JAPAN  
PI US 2003139518 A1 20030724  
AI US 2002-284376 A1 20021031 (10)  
RLI Continuation-in-part of Ser. No. US 2002-240793, filed on 4 Oct 2002,  
PENDING A 371 of International Ser. No. WO 2001-JP1416, filed on 26 Feb  
2001, UNKNOWN  
PRAI JP 2000-200125081 20000426

DT Utility  
FS APPLICATION  
LN.CNT 1486

INCL INCLM: 524/495.000  
INCLS: 524/496.000  
NCL NCLM: 524/495.000  
NCLS: 524/496.000  
IC [7]  
ICM: C08K003-04  
CAS INDEXING IS AVAILABLE FOR THIS PATENT.

L6 ANSWER 6 OF 9 USPATFULL on STN  
AN 2003:195152 USPATFULL  
TI Electrically conductive resin composition and production process thereof  
IN Miyoshi, Takaaki, Kimitsu, JAPAN  
Hashimoto, Kazuhiko, Sodegaura, JAPAN  
PI US 2003134963 A1 20030717  
AI US 2002-284091 A1 20021031 (10)  
RLI Continuation-in-part of Ser. No. US 2002-240793, filed on 4 Oct 2002,  
PENDING A 371 of International Ser. No. WO 2001-JP1416, filed on 26 Feb  
2001, UNKNOWN  
PRAI JP 2000-125081 20000426  
DT Utility  
FS APPLICATION  
LN.CNT 1391  
INCL INCLM: 524/495.000  
INCLS: 524/496.000  
NCL NCLM: 524/495.000  
NCLS: 524/496.000  
IC [7]  
ICM: C08K003-04  
CAS INDEXING IS AVAILABLE FOR THIS PATENT.

L6 ANSWER 7 OF 9 USPATFULL on STN  
AN 2003:170923 USPATFULL  
TI Conductive resin composition and process for producing the same  
IN Miyoshi, Takaaki, Chiba, JAPAN  
Hashimoto, Kazuhiko, Chiba, JAPAN  
PI US 2003116757 A1 20030626  
AI US 2002-240793 A1 20021004 (10)  
WO 2001-JP1416 20010226  
DT Utility  
FS APPLICATION  
LN.CNT 1923  
INCL INCLM: 252/511.000  
NCL NCLM: 252/511.000  
IC [7]  
ICM: H01B001-06  
ICS: H01C001-00  
CAS INDEXING IS AVAILABLE FOR THIS PATENT.

L6 ANSWER 8 OF 9 USPATFULL on STN  
AN 2003:65633 USPATFULL  
TI Modified polyphenylene ether  
IN Ishii, Yoshiyuki, Shizuoka-ken, JAPAN  
Sorita, Kumi, Tokyo, JAPAN  
PI US 2003045757 A1 20030306  
AI US 2002-182648 A1 20020731 (10)  
WO 2001-JP1358 20010223  
PRAI JP 2000-45418 20000223  
JP 2000-79660 20000322  
DT Utility  
FS APPLICATION  
LN.CNT 1965  
INCL INCLM: 568/660.000  
INCLS: 528/219.000; 528/176.000  
NCL NCLM: 568/660.000  
NCLS: 528/219.000; 528/176.000  
IC [7]  
ICM: C08G063-00  
ICS: C08G065-38; C07C043-263

CAS INDEXING IS AVAILABLE FOR THIS PATENT.

L6 ANSWER 9 OF 9 USPATFULL on STN  
AN 1999:4831 USPATFULL  
TI Polyamide resin composition  
IN Nakahashi, Jun-ichi, Chiba, Japan  
Horio, Mitsuhiro, Chiba, Japan  
Yoshida, Kazuo, Chiba, Japan  
PA Asahi Kasei Kogyo Kabushiki Kaisha, Osaka, Japan (non-U.S. corporation)  
PI US 5859176 19990112  
WO 9616123 19960530  
AI US 1997-793934 19970310 (8)  
WO 1994-JP1947 19941118  
19970310 PCT 371 date  
19970310 PCT 102(e) date  
DT Utility  
FS Granted  
LN.CNT 1538  
INCL INCLM: 528/310.000  
INCLS: 528/322.000; 528/332.000; 524/186.000; 524/600.000; 524/606.000;  
525/092.000; 525/397.000; 525/905.000  
NCL NCLM: 528/310.000  
NCLS: 524/186.000; 524/600.000; 524/606.000; 525/092.000B; 525/397.000;  
525/905.000; 528/322.000; 528/332.000  
IC [6]  
ICM: C08G069-08  
ICS: C08G073-10; C08L077-00  
EXF 524/600; 524/186; 524/606; 525/92; 525/397; 525/905; 528/310; 528/322;  
528/332

CAS INDEXING IS AVAILABLE FOR THIS PATENT.

=> s (polyphenylene ether# or polyarylene ether#) and low molecular weight#  
L8 2474 (POLYPHENYLENE ETHER# OR POLYARYLENE ETHER#) AND LOW MOLECULAR  
WEIGHT#

=> s 18 and phenol and catalyst# and oxygen containing gas  
L9 112 L8 AND PHENOL AND CATALYST# AND OXYGEN CONTAINING GAS

=> s 19 and copper and halogen? and diamine#  
L10 43 L9 AND COPPER AND HALOGEN? AND DIAMINE#

=> s 110 and good solvent# and poor solvent#  
L11 10 L10 AND GOOD SOLVENT# AND POOR SOLVENT#

=> s 111 and precipitat?  
L12 10 L11 AND PRECIPITAT?

=> s 112 and alcohol#  
L13 10 L12 AND ALCOHOL#

=> s 113 and slurry  
L14 4 L13 AND SLURRY

=> d 114 1-4

L14 ANSWER 1 OF 4 USPATFULL on STN  
AN 2002:224692 USPATFULL  
TI Method of preparing a poly(arylene ether), and a poly(arylene ether)  
prepared thereby  
IN Singh, Probjot, Delmar, NY, United States  
Ingelbrecht, Hugo Gerard Eduard, Essen, BELGIUM  
Parrillo, David, Schenectady, NY, United States  
Parthasarathy, Mukund, Delmar, NY, United States  
PA General Electric Company, Pittsfield, MA, United States (U.S.  
corporation)  
PI US 6444779 B1 20020903 No  
AI US 2002-683806 20020219 (9)

*Priority date March 8, 2002*

RLI Continuation of Ser. No. US 2001-681895, filed on 21 Jun 2001  
DT Utility  
FS GRANTED  
LN.CNT 904  
INCL INCLM: 528/217.000  
INCLS: 528/212.000; 528/214.000; 528/502.000R; 528/503.000; 425/074.000  
NCL NCLM: 528/217.000  
NCLS: 425/074.000; 528/212.000; 528/214.000; 528/502.000R; 528/503.000  
IC [7]  
ICM: C08G065-38  
ICS: C08G065-44  
EXF 528/217; 528/212; 528/214; 528/502R; 528/503; 425/74  
CAS INDEXING IS AVAILABLE FOR THIS PATENT.

L14 ANSWER 2 OF 4 USPATFULL on STN  
AN 2002:209642 USPATFULL  
TI Method of preparing a poly (arylene ether) and a poly (arylene ether) prepared thereby  
IN Birsak, Joop, Halstere, NETHERLANDS  
Ingelbrecht, Hugo Gerard Eduard, Essen, BELGIUM  
Parrillo, David, Schenectady, NY, United States  
Parthasarathy, Mukund, Delmar, NY, United States  
Singh, Probot, Delmar, NY, United States  
PA General Electric Company, Pittsfield, MA, United States (U.S. corporation)  
PI US 6437084 B1 20020820 100  
AI US 2001-683037 20011112 (9)  
DT Utility  
FS GRANTED  
LN.CNT 935  
INCL INCLM: 528/217.000  
INCLS: 528/104.000; 528/212.000; 528/214.000; 528/483.000; 528/491.000;  
528/495.000; 528/496.000; 528/497.000; 528/502.000R; 528/503.000  
NCL NCLM: 528/217.000  
NCLS: 528/104.000; 528/212.000; 528/214.000; 528/483.000; 528/491.000;  
528/495.000; 528/496.000; 528/497.000; 528/502.000R; 528/503.000  
IC [7]  
ICM: C08G065-38  
ICS: C08G065-44  
EXF 528/86; 528/104; 528/483; 528/471; 528/495; 528/496; 528/497; 528/503;  
528/217; 528/212; 528/214; 528/491  
CAS INDEXING IS AVAILABLE FOR THIS PATENT.

L14 ANSWER 3 OF 4 USPATFULL on STN  
AN 2002:144353 USPATFULL  
TI Method of preparing a poly(arylene ether), and a poly(arylene ether) prepared thereby  
IN Singh, Probot, Delmar, NY, United States  
Ingelbrecht, Hugo Gerard Eduard, Essen, BELGIUM  
Parrillo, David, Schenectady, NY, United States  
Parthasarathy, Mukund, Delmar, NY, United States  
PA General Electric Company, Pittsfield, MA, United States (U.S. corporation)  
PI US 6407200 B1 20020618 100  
AI US 2001-681895 20010621 (9)  
DT Utility  
FS GRANTED  
LN.CNT 926  
INCL INCLM: 528/217.000  
INCLS: 528/212.000; 528/214.000; 528/502.000R; 528/503.000; 264/050.000;  
264/045.900  
NCL NCLM: 528/217.000  
NCLS: 264/045.900; 264/050.000; 528/212.000; 528/214.000; 528/502.000R;  
528/503.000  
IC [7]  
ICM: C08G065-38  
ICS: C08G065-44  
EXF 528/217; 528/212; 528/214; 528/502R; 528/503; 264/50; 264/45.9

CAS INDEXING IS AVAILABLE FOR THIS PATENT.

L14 ANSWER 4 OF 4 USPATFULL on STN  
AN 84:42786 USPATFULL  
TI Process for preparing polyphenylene ethers  
IN Dalton, William O., Parkersburg, WV, United States  
Rinehart, Michael K., Parkersburg, WV, United States  
Sugio, Akitoshi, Tokyo, Japan  
PA Borg-Warner Chemicals, Inc., Parkersburg, WV, United States (U.S.  
corporation)  
PI US 4463164 19840731  
AI US 1983-466746 19830215 (6)  
DT Utility  
FS Granted  
LN.CNT 560  
INCL INCLM: 528/212.000  
INCLS: 526/068.000; 526/069.000; 526/070.000; 528/086.000; 528/214.000;  
528/215.000; 528/217.000; 528/486.000; 528/487.000; 528/490.000;  
528/496.000; 528/499.000; 528/502.000  
NCL NCLM: 528/212.000  
NCLS: 526/068.000; 526/069.000; 526/070.000; 528/086.000; 528/214.000;  
528/215.000; 528/217.000; 528/486.000; 528/487.000; 528/490.000;  
528/496.000; 528/499.000  
IC [3]  
ICM: C08G065-46  
EXF 528/212; 528/86; 528/486; 528/487; 528/490; 528/496; 528/499; 528/502;  
528/214; 528/215; 528/217; 526/68-70  
CAS INDEXING IS AVAILABLE FOR THIS PATENT.

=> d 113 1-10

L13 ANSWER 1 OF 10 EPFULL COPYRIGHT 2005 EPO/FIZ KA on STN  
AN 2001:46105 EPFULL  
DUPD 20020918 DUPW 200238  
TIEN Production process of polyphenylene ether.  
TIFR Procede pour la production de poly(ether de phenylene).  
TIDE Verfahren zur Herstellung von Polyphenylenether.  
IN Mitsui, Akira, 2-31, 3-10-1, Fukuoudai, Sodegaura-shi, Chiba 299-0261,  
JP;  
Takeda, Yuji, 4-16, Hinagahigashi 2-chome, Yokkaichi-shi, Mie  
510-0886, JP  
PA Asahi Kasei Kabushiki Kaisha, 2-6, Dojimahama 1-chome, Kita-ku,  
Osaka-shi, Osaka 530-8205, JP;  
MITSUBISHI GAS CHEMICAL COMPANY, INC., 5-2, Marunouchi 2-chome,  
Chiyoda-Ku, Tokyo 100-0005, JP  
PAN 219576; 287630  
AG Prins, Adrianus Willem, et al, Vereenigde, Nieuwe Parklaan 97, 2587 BN  
Den Haag, NL  
AGN 20903  
LAF English  
LA English  
LAP English  
TL German; English; French  
DT Patent  
PIT EPA1 Application published with search report  
PI EP 1167420 A1 20020102  
DS DE NL  
AI EP 2001-202378 A 20010619  
PRAI JP 2000-183144 A 20000619  
IC.VER 7  
ICM C08G065-44  
AN 2001:46105 EPFULL UP 20050127  
DUPD 20050126 DUPW 200504  
TIEN Production process of polyphenylene ether.  
TIFR Procede pour la production de poly(ether de phenylene).

TIDE Verfahren zur Herstellung von Polyphenylenether.  
IN Mitsui, Akira, 2-31, 3-10-1, Fukuoudai, Sodegaura-shi, Chiba 299-0261,  
JP;  
Takeda, Yuji, 4-16, Hinagahigashi 2-chome, Yokkaichi-shi, Mie  
510-0886, JP  
PA Asahi Kasei Chemicals Corporation, 1-2, Yuraku-cho 1-chome, Chiyoda-ku,  
Tokyo 100-8440, JP;  
MITSUBISHI GAS CHEMICAL COMPANY, INC., 5-2, Marunouchi 2-chome,  
Chiyoda-Ku, Tokyo 100-0005, JP  
PAN 4659480; 287630  
AG Prins, Adrianus Willem, Mr. Ir., et al, Vereenigde, Nieuwe Parklaan 97,  
2587 BN Den Haag, NL  
AGN 20903  
LAF English  
LA English  
LAP English  
TL German; English; French  
DT Patent  
PIT EPB1 Granted patent  
PI EP 1167420 B1 20040204  
DS DE NL  
AI EP 2001-202378 A 20010619  
PRAI JP 2000-183144 A 20000619  
REP US 4092294 A  
US 4477651 A  
US 4788277 A  
IC.VER 7  
ICM C08G065-44

L13 ANSWER 2 OF 10 EPFULL COPYRIGHT 2005 EPO/FIZ KA on STN

AN 2001:46104 EPFULL  
DUPD 20040901 DUPW 200436  
TIEN Production process of **polyphenylene ether**.  
TIFR Procede pour la production d'esther de polyphenylene.  
TIDE Verfahren zur Herstellung von Polyphenylenether.  
IN Mitsui, Akira, 2-31, 3-10-1, Fukuoudai, Sodegaura-shi, Chiba 299-0261,  
JP;  
Takeda, Yuji, 4-16, Hinagahigashi 2-chome, Yokkaichi-shi, Mie  
510-0886, JP  
PA Asahi Kasei Chemicals Corporation, 1-2, Yuraku-cho 1-chome, Chiyoda-ku,  
Tokyo 100-8440, JP;  
MITSUBISHI GAS CHEMICAL COMPANY, INC., 5-2, Marunouchi 2-chome,  
Chiyoda-Ku, Tokyo 100-0005, JP  
PAN 4659480; 287630  
AG Prins, Adrianus Willem, Mr. Ir., et al, Vereenigde, Nieuwe Parklaan 97,  
2587 BN Den Haag, NL  
AGN 20903  
LAF English  
LA English  
LAP English  
TL German; English; French  
DT Patent  
PIT EPA2 Application published without search report  
PI EP 1167419 A2 20020102  
EP 1167419 A3 20031210  
DS DE NL  
AI EP 2001-202376 A 20010619  
PRAI JP 2000-183145 A 20000619  
IC.VER 7  
ICM C08G065-44

AN 2001:46104 EPFULL  
DUPD 20031210 DUPW 200350  
TIEN Production process of **polyphenylene ether**.  
TIFR Procede pour la production d'esther de polyphenylene.  
TIDE Verfahren zur Herstellung von Polyphenylenether.  
IN Mitsui, Akira, 2-31, 3-10-1, Fukuoudai, Sodegaura-shi, Chiba 299-0261,

JP;  
Takeda, Yuji, 4-16, Hinagahigashi 2-chome, Yokkaichi-shi, Mie  
510-0886, JP  
PA Asahi Kasei Kabushiki Kaisha, 2-6, Dojimahama 1-chome, Kita-ku,  
Osaka-shi, Osaka 530-8205, JP;  
MITSUBISHI GAS CHEMICAL COMPANY, INC., 5-2, Marunouchi 2-chome,  
Chiyoda-Ku, Tokyo 100-0005, JP  
PAN 219576; 287630  
AG Prins, Adrianus Willem, et al, Vereenigde, Nieuwe Parklaan 97, 2587 BN  
Den Haag, NL  
AGN 20903  
LAF English  
LA English  
LAP English  
TL German; English; French  
DT Patent  
PIT EPA3 Separate publication of search report  
PI EP 1167419 A3 20031210  
DS AT BE CH CY DE DK ES FI FR GB GR IE IT LI LU MC NL PT SE TR  
AI EP 2001-202376 A 20010619  
PRAI JP 2000-183145 A 20000619  
IC.VER 7  
ICM C08G065-44

L13 ANSWER 3 OF 10 USPATFULL on STN  
AN 2002:224692 USPATFULL  
TI Method of preparing a poly(arylene ether), and a poly(arylene ether)  
prepared thereby  
IN Singh, Probot, Delmar, NY, United States  
Ingelbrecht, Hugo Gerard Eduard, Essen, BELGIUM  
Parrillo, David, Schenectady, NY, United States  
Parthasarathy, Mukund, Delmar, NY, United States  
PA General Electric Company, Pittsfield, MA, United States (U.S.  
corporation)  
PI US 6444779 B1 20020903  
AI US 2002-683806 20020219 (9)  
RLI Continuation of Ser. No. US 2001-681895, filed on 21 Jun 2001  
DT Utility  
FS GRANTED  
LN.CNT 904  
INCL INCLM: 528/217.000  
INCLS: 528/212.000; 528/214.000; 528/502.000R; 528/503.000; 425/074.000  
NCL NCLM: 528/217.000  
NCLS: 425/074.000; 528/212.000; 528/214.000; 528/502.000R; 528/503.000  
IC [7]  
ICM: C08G065-38  
ICS: C08G065-44  
EXF 528/217; 528/212; 528/214; 528/502R; 528/503; 425/74  
CAS INDEXING IS AVAILABLE FOR THIS PATENT.

L13 ANSWER 4 OF 10 USPATFULL on STN  
AN 2002:209642 USPATFULL  
TI Method of preparing a poly (arylene ether) and a poly (arylene ether)  
prepared thereby  
IN Birsak, Joop, Halstere, NETHERLANDS  
Ingelbrecht, Hugo Gerard Eduard, Essen, BELGIUM  
Parrillo, David, Schenectady, NY, United States  
Parthasarathy, Mukund, Delmar, NY, United States  
Singh, Probot, Delmar, NY, United States  
PA General Electric Company, Pittsfield, MA, United States (U.S.  
corporation)  
PI US 6437084 B1 20020820  
AI US 2001-683037 20011112 (9)  
DT Utility  
FS GRANTED  
LN.CNT 935  
INCL INCLM: 528/217.000  
INCLS: 528/104.000; 528/212.000; 528/214.000; 528/483.000; 528/491.000;

NCL            528/495.000; 528/496.000; 528/497.000; 528/502.000R; 528/503.000  
NCLM: 528/217.000  
NCLS: 528/104.000; 528/212.000; 528/214.000; 528/483.000; 528/491.000;  
528/495.000; 528/496.000; 528/497.000; 528/502.000R; 528/503.000  
IC            [7]  
ICM: C08G065-38  
ICS: C08G065-44  
EXF        528/86; 528/104; 528/483; 528/471; 528/495; 528/496; 528/497; 528/503;  
528/217; 528/212; 528/214; 528/491  
CAS INDEXING IS AVAILABLE FOR THIS PATENT.

L13 ANSWER 5 OF 10 USPATFULL on STN  
AN 2002:144353 USPATFULL  
TI Method of preparing a poly(arylene ether), and a poly(arylene ether)  
prepared thereby  
IN Singh, Probjot, Delmar, NY, United States  
    Ingelbrecht, Hugo Gerard Eduard, Essen, BELGIUM  
    Parrillo, David, Schenectady, NY, United States  
    Parthasarathy, Mukund, Delmar, NY, United States  
PA General Electric Company, Pittsfield, MA, United States (U.S.  
corporation)  
PI US 6407200            B1    20020618  
AI US 2001-681895            20010621 (9)  
DT Utility  
FS GRANTED  
LN.CNT 926  
INCL INCLM: 528/217.000  
INCLS: 528/212.000; 528/214.000; 528/502.000R; 528/503.000; 264/050.000;  
264/045.900  
NCL NCLM: 528/217.000  
NCLS: 264/045.900; 264/050.000; 528/212.000; 528/214.000; 528/502.000R;  
528/503.000  
IC            [7]  
ICM: C08G065-38  
ICS: C08G065-44  
EXF        528/217; 528/212; 528/214; 528/502R; 528/503; 264/50; 264/45.9  
CAS INDEXING IS AVAILABLE FOR THIS PATENT.

L13 ANSWER 6 OF 10 USPATFULL on STN  
AN 2002:22610 USPATFULL  
TI Production process of **polyphenylene ether**  
IN Mitsui, Akira, Chiba, JAPAN  
    Takeda, Yuji, Mie, JAPAN  
PI US 2002013446            A1    20020131  
    US 6521735            B2    20030218  
AI US 2001-883264            A1    20010619 (9)  
PRAI JP 2000-183144            20000619  
DT Utility  
FS APPLICATION  
LN.CNT 836  
INCL INCLM: 528/215.000  
INCLS: 528/217.000; 528/490.000; 528/492.000; 528/482.000; 502/165.000  
NCL NCLM: 528/215.000  
NCLS: 502/165.000; 528/217.000; 528/482.000; 528/490.000; 528/492.000  
IC            [7]  
ICM: C08G065-38  
ICS: C08G065-44  
CAS INDEXING IS AVAILABLE FOR THIS PATENT.

L13 ANSWER 7 OF 10 USPATFULL on STN  
AN 2002:17434 USPATFULL  
TI Production process of **polyphenylene ether**  
IN Mitsui, Akira, Chiba, JAPAN  
    Takeda, Yuji, Mie, JAPAN  
PI US 2002010314            A1    20020124  
    US 6489439            B2    20021203  
AI US 2001-883388            A1    20010619 (9)  
PRAI JP 2000-183145            20000619

DT Utility  
FS APPLICATION  
LN.CNT 887  
INCL INCLM: 528/501.000  
INCLS: 528/215.000; 528/217.000; 528/490.000; 528/492.000; 502/165.000  
NCLS: 502/165.000; 528/086.000; 528/215.000; 528/217.000; 528/483.000;  
528/492.000

IC [7]  
ICM: C08G065-44  
ICS: C08G065-38; C08F006-08

CAS INDEXING IS AVAILABLE FOR THIS PATENT.

L13 ANSWER 8 OF 10 USPATFULL on STN  
AN 84:42786 USPATFULL  
TI Process for preparing **polyphenylene ethers**  
IN Dalton, William O., Parkersburg, WV, United States  
Rinehart, Michael K., Parkersburg, WV, United States  
Sugio, Akitoshi, Tokyo, Japan  
PA Borg-Warner Chemicals, Inc., Parkersburg, WV, United States (U.S.  
corporation)  
PI US 4463164 19840731  
AI US 1983-466746 19830215 (6)  
DT Utility  
FS Granted  
LN.CNT 560  
INCL INCLM: 528/212.000  
INCLS: 526/068.000; 526/069.000; 526/070.000; 528/086.000; 528/214.000;  
528/215.000; 528/217.000; 528/486.000; 528/487.000; 528/490.000;  
528/496.000; 528/499.000; 528/502.000  
NCL NCLM: 528/212.000  
NCLS: 526/068.000; 526/069.000; 526/070.000; 528/086.000; 528/214.000;  
528/215.000; 528/217.000; 528/486.000; 528/487.000; 528/490.000;  
528/496.000; 528/499.000  
IC [3]  
ICM: C08G065-46  
EXF 528/212; 528/86; 528/486; 528/487; 528/490; 528/496; 528/499; 528/502;  
528/214; 528/215; 528/217; 526/68-70  
CAS INDEXING IS AVAILABLE FOR THIS PATENT.

L13 ANSWER 9 OF 10 USPAT2 on STN  
AN 2002:22610 USPAT2  
TI Production process of **polyphenylene ether**  
IN Mitsui, Akira, Chiba, JAPAN  
Takeda, Yuji, Mie, JAPAN  
PA Asahi Kasei Kabushiki Kaisha, Osaka, JAPAN (non-U.S. corporation)  
Mitsubishi Gas Chemical Company, Inc., Tokyo, JAPAN (non-U.S.  
corporation)  
PI US 6521735 B2 20030218  
AI US 2001-883264 20010619 (9)  
PRAI JP 2000-183144 20000619  
DT Utility  
FS GRANTED  
LN.CNT 812  
INCL INCLM: 528/215.000  
INCLS: 528/217.000; 528/490.000; 528/492.000; 528/482.000; 502/165.000  
NCL NCLM: 528/215.000  
NCLS: 502/165.000; 528/217.000; 528/482.000; 528/490.000; 528/492.000  
IC [7]  
ICM: C08G065-38  
ICS: C08G065-44  
EXF 528/215; 528/217; 528/490; 528/492; 528/482; 502/165  
CAS INDEXING IS AVAILABLE FOR THIS PATENT.

L13 ANSWER 10 OF 10 USPAT2 on STN  
AN 2002:17434 USPAT2  
TI Production process of **polyphenylene ether**  
IN Mitsui, Akira, Chiba, JAPAN  
Takeda, Yuji, Mie, JAPAN

PA Asahi Kasei Kabushiki Kaisha, Osaka, JAPAN (non-U.S. corporation)  
Mitsubishi Gas Chemical Company, Inc., Tokyo, JAPAN (non-U.S.  
corporation)

PI US 6489439 B2 20021203

AI US 2001-883388 20010619 (9)

PRAI JP 2000-183145 20000619

DT Utility

FS GRANTED

LN.CNT 863

INCL INCLM: 528/561.000  
INCLS: 528/492.000; 528/483.000; 528/086.000; 528/215.000; 528/217.000;  
502/165.000  
NCLS: 502/165.000; 528/086.000; 528/215.000; 528/217.000; 528/483.000;  
528/492.000

IC [7]  
ICM: C08G065-44  
ICS: C08G065-38; C08F006-08

EXF 528/501; 528/492; 528/483; 528/86; 528/215; 528/217; 502/165

CAS INDEXING IS AVAILABLE FOR THIS PATENT.

=>

Day : Wednesday

Date: 3/16/2005  
Time: 11:15:00**PALM INTRANET****Inventor Name Search Result**

Your Search was:

Last Name = MITSUI

First Name = AKIRA

Application#	Patent#	Status	Date Filed	Title	Inventor Name
<a href="#"><u>06845064</u></a>	D298643	150	03/19/1986	GOLF IRON CLUB	MITSUI, AKIRA
<a href="#"><u>07489954</u></a>	5209835	150	03/07/1990	METHOD FOR PRODUCING A SPECIFIED ZIRCONIUM-SILICON AMORPHOUS OXIDE FILM COMPOSITION BY SPUTTERING	MITSUI, AKIRA
<a href="#"><u>07589616</u></a>	5210073	150	09/28/1990	A METHOD FOR TREATING CANCER THERAPY RADIATION DAMAGE OR ARTERIOSCLEROSIS USING HUMAN ADF	MITSUI, AKIRA
<a href="#"><u>07671801</u></a>	Not Issued	166	04/22/1991	FILM COMPRISING SILICON DIOXIDE AS THE MAIN COMPONENT AND METHOD FOR ITS PRODUCTION	MITSUI, AKIRA
<a href="#"><u>07834201</u></a>	Not Issued	166	02/12/1992	LAMINATED GLASS STRUCTURE	MITSUI, AKIRA
<a href="#"><u>07875392</u></a>	Not Issued	161	04/29/1992	PHARMACEUTICAL COMPOSITION COMPRISING HUMAN ADF	MITSUI, AKIRA
<a href="#"><u>07936281</u></a>	5354446	150	08/28/1992	CERAMICS ROTATABLE MAGNETRON SPUTTERING CATHODE TARGET AND PROCESS FOR ITS PRODUCTION	MITSUI, AKIRA
<a href="#"><u>08003417</u></a>	5464674	150	01/12/1993	MAGNETIC RECORDING MEDIUM AND METHOD FOR ITS PRODUCTION	MITSUI, AKIRA
<a href="#"><u>08055782</u></a>	Not Issued	166	05/03/1993	FILM COMPRISING SILICON DIOXIDE AS THE MAIN COMPONENT AND METHOD FOR ITS PRODUCTION	MITSUI, AKIRA

<u>08078689</u>	Not Issued	161	06/21/1993	PREVENTIVE OR THERAPEUTIC MEDICINE FOR PANCREATITIS	MITSUI, AKIRA
<u>08080522</u>	<u>5458753</u>	250	06/24/1993	TRANSPARENT CONDUCTIVE FILM CONSISTING OF ZINC OXIDE AND GALLIUM	MITSUI, AKIRA
<u>08135186</u>	<u>5346770</u>	150	10/12/1993	LAMINATED GLASS STRUCTURE	MITSUI, AKIRA
<u>08323579</u>	<u>5605609</u>	150	10/17/1994	METHOD FOR FORMING LOW REFRACTIVE INDEX FILM COMPRISING SILICON DIOXIDE	MITSUI, AKIRA
<u>08348102</u>	<u>5618133</u>	150	11/25/1994	VIBRATING MECHANISM AND APPARATUS FOR GENERATING VIBRATIONS FOR A VIBRATION COMPACTING ROLLER WITH VARIABLE AMPLITUDE	MITSUI, AKIRA
<u>08429845</u>	<u>5772862</u>	150	04/27/1995	FILM COMPRISING SILICON DIOXIDE AS THE MAIN COMPONENT AND METHOD FOR ITS PRODUCTION	MITSUI, AKIRA
<u>08515805</u>	<u>5736267</u>	150	08/16/1995	TRANSPARENT CONDUCTIVE FILM AND METHOD FOR ITS PRODUCTION, AND SPUTTERING TARGET	MITSUI, AKIRA
<u>08631125</u>	<u>5788408</u>	150	04/12/1996	VIBRATORY PNEUMATIC TIRE ROLLER	MITSUI, AKIRA
<u>08699869</u>	Not Issued	161	08/20/1996	FILM COMPRISING SILICON DIOXIDE AS THE MAIN COMPONENT AND METHOD FOR ITS PRODUCTION	MITSUI, AKIRA
<u>08912361</u>	<u>6146765</u>	150	08/18/1997	TRANSPARENT CONDUCTIVE FILM AND METHOD FOR ITS PRODUCTION AND SPUTTERING TARGET	MITSUI, AKIRA
<u>08987386</u>	<u>5984572</u>	150	12/09/1997	VIBRATORY GENERATING MECHANISM AND VIBRATORY ROLLER UTILIZING VIBRATORY GENERATING MECHANISM	MITSUI, AKIRA
<u>09011749</u>	<u>6193856</u>	150	03/12/1998	TARGET AND PROCESS FOR ITS PRODUCTION, AND METHOD FOR FORMING A FILM HAVING A HIGHLY REFRACTIVE INDEX	MITSUI, AKIRA

<u>09040396</u>	Not Issued	161	03/18/1998	film comprising silicon dioxide as the main component and method for its production	MITSUI, AKIRA
<u>09175964</u>	<u>6042752</u>	150	10/21/1998	transparent conductive film, sputtering target and transparent conductive film-bonded substrate	MITSUI, AKIRA
<u>09437443</u>	<u>6261982</u>	150	11/10/1999	cordierite ceramic filter	MITSUI, AKIRA
<u>09622069</u>	<u>6596135</u>	150	08/31/2000	sputtering target, transparent conductive film, and method for producing the same	MITSUI, AKIRA
<u>09647917</u>	<u>6639318</u>	150	10/13/2000	integrated circuit device and its manufacturing method	MITSUI, AKIRA
<u>09729102</u>	<u>6334938</u>	150	12/05/2000	target and process for its production, and method for forming a film having a high refractive index	MITSUI, AKIRA
<u>09870697</u>	<u>6402424</u>	150	06/01/2001	vibratory roller	MITSUI, AKIRA
<u>09883264</u>	<u>6521735</u>	150	06/19/2001	production process of polyphenylene ether	MITSUI, AKIRA
<u>09883277</u>	<u>6586567</u>	150	06/19/2001	production process of polyphenylene ether	MITSUI, AKIRA
<u>09883388</u>	<u>6489439</u>	150	06/19/2001	production process of polyphenylene ether	MITSUI, AKIRA
<u>09925441</u>	Not Issued	161	08/10/2001	electroconductive nitride film, its production method, and antireflector	MITSUI, AKIRA
<u>09926028</u>	<u>6806049</u>	150	08/16/2001	method for analyzing gene expression frequency	MITSUI, AKIRA
<u>09964625</u>	<u>6440278</u>	150	09/28/2001	target and process for its production, and method for forming a film having a high refractive index	MITSUI, AKIRA
<u>10121695</u>	<u>6800182</u>	150	04/15/2002	sputtering target, process for its production and film	MITSUI, AKIRA

				FORMING METHOD	
<a href="#"><u>10191321</u></a>	<a href="#"><u>6743343</u></a>	150	07/10/2002	TARGET AND PROCESS FOR ITS PRODUCTION, AND METHOD FOR FORMING A FILM HAVING A HIGH REFRACTIVE INDEX	MITSUI, AKIRA
<a href="#"><u>10485963</u></a>	Not Issued	041	02/06/2004	2, 6-DIMETHYPHENOL COMPOSITION	MITSUI, AKIRA
<a href="#"><u>10491490</u></a>	Not Issued	030	04/01/2004	POLYPHENYLENE ETHER RESIN COMPOSITION	MITSUI, AKIRA
<a href="#"><u>10500701</u></a>	Not Issued	030	07/02/2004	LOW MOLECULAR WEIGHT POLYPHENYLENE ETHER	MITSUI, AKIRA
<a href="#"><u>10785130</u></a>	Not Issued	030	02/24/2004	VIBRATORY MECHANISM AND VIBRATORY ROLLER	MITSUI, AKIRA
<a href="#"><u>10997873</u></a>	Not Issued	020	11/29/2004	PHARMACEUTICAL COMPOSITION FOR SUPPRESSION OF THE EXPRESSION OF ATP CITRATE LYASE AND USE THEREOF	MITSUI, AKIRA
<a href="#"><u>09050944</u></a>	<a href="#"><u>6200902</u></a>	150	03/31/1998	METHOD OF ETCHING A LAYER IN A SEMICONDUCTOR DEVICE	MITSUIKI, AKIRA
<a href="#"><u>09233089</u></a>	<a href="#"><u>6376383</u></a>	150	01/19/1999	METHOD FOR ETCHING SILICON LAYER	MITSUIKI, AKIRA
<a href="#"><u>09306625</u></a>	Not Issued	161	05/06/1999	PROCESS FOR FABRICATING SEMICONDUCTOR DEVICE WITHOUT ETCHING RESIDUE PRODUCED DURING ETCHING TO OXIDE LAYER	MITSUIKI, AKIRA
<a href="#"><u>09342186</u></a>	Not Issued	161	06/29/1999	METHOD OF ETCHING SILICON-BASED MATERIAL	MITSUIKI, AKIRA
<a href="#"><u>09571733</u></a>	<a href="#"><u>6372602</u></a>	150	05/15/2000	METHOD OF FORMING A SHALLOW TRENCH ISOLATION STRUCTURE IN A SEMICONDUCTOR DEVICE	MITSUIKI, AKIRA
<a href="#"><u>10023847</u></a>	<a href="#"><u>6716761</u></a>	150	12/21/2001	METHOD OF FORMING FINE PATTERNS	MITSUIKI, AKIRA

Inventor Search Completed: No Records to Display.

<b>Search Another: Inventor</b>	<b>Last Name</b>	<b>First Name</b>
	<input type="text" value="Mitsui"/>	<input type="text" value="Akira"/>
		<input type="button" value="Search"/>

To go back use Back button on your browser toolbar.

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Day : Wednesday

Date: 3/16/2005

Time: 11:15:52

**PALM INTRANET****Inventor Name Search Result**

Your Search was:

Last Name = FURUKAWA

First Name = HIROSHI

Application#	Patent#	Status	Date Filed	Title	Inventor Name
<a href="#"><u>06051015</u></a>	Not Issued	161	06/22/1979	CINECAMERA EQUIPMENT CAPABLE OF SYNCHRONOUS SOUND RECORDING	FURUKAWA, HIROSHI
<a href="#"><u>06126822</u></a>	4327231	150	03/03/1980	PROCESS FOR THE PRODUCTION OF TERTIARY ALCOHOLS	FURUKAWA, HIROSHI
<a href="#"><u>06158314</u></a>	4285381	150	06/10/1980	CURABLE COMPOSITION FOR HARD RUBBER AND THE USE THEREOF	FURUKAWA, HIROSHI
<a href="#"><u>06209168</u></a>	4299800	150	11/21/1980	METHOD OF REMOVING OXYGEN FROM A GAS CONTAINING AN UNSATURATED HYDROCARBON	FURUKAWA, HIROSHI
<a href="#"><u>06230046</u></a>	4361677	150	04/29/1981	CURABLE COMPOSITION FOR HARD RUBBER AND THE USE THEREOF	FURUKAWA, HIROSHI
<a href="#"><u>06324545</u></a>	Not Issued	168	11/24/1981	CONJUGATED DIENE BLOCK POLYMER AND PROCESS FOR PREPARING THE SAME	FURUKAWA, HIROSHI
<a href="#"><u>06324547</u></a>	Not Issued	161	11/24/1981	COMPOSITION FOR TREAD RUBBER OR TIRES	FURUKAWA, HIROSHI
<a href="#"><u>06324548</u></a>	4385151	150	11/24/1981	COMPOSITION CONTAINING ISOPRENE POLYMER	FURUKAWA, HIROSHI
<a href="#"><u>06324591</u></a>	Not Issued	161	11/24/1981	CONJUGATED DIENE RUBBER COMPOSITION	FURUKAWA, HIROSHI
<a href="#"><u>06339181</u></a>	Not Issued	161	01/13/1982	CINECAMERA EQUIPMENT CAPABLE OF SYNCHRONOUS SOUND RECORDING	FURUKAWA, HIROSHI
<a href="#"><u>06371020</u></a>	4537936	150	04/22/1982	DIENE RUBBER COMPOSITION, METHOD OF PREPARING THE SAME AND TIRE EMPLOYING SAID	FURUKAWA, HIROSHI

				COMPOSITION	
<u>06385874</u>	Not Issued	161	06/07/1982	ELASTOMER COMPOSITION, A VULCANIZED COMPOSITION AND A TIRE EMPLOYING SAID ELASTOMER COMPOSITION	FURUKAWA, HIROSHI
<u>06470506</u>	4471093	150	02/28/1983	ELASTOMER COMPOSITION COMPRISING A BLEND OF SBR RUBBERS	FURUKAWA, HIROSHI
<u>06477583</u>	4436873	150	03/21/1983	CONJUGATED DIENE BLOCK POLYMER AND PROCESS FOR PREPARING THE SAME	FURUKAWA, HIROSHI
<u>06478917</u>	4657384	150	03/25/1983	PHOTOELECTRIC DEVICE	FURUKAWA, HIROSHI
<u>06480348</u>	4523618	150	03/30/1983	BRANCHED POLYMER, PROCESS FOR THE PREPARATION THEREOF, TIRE TREAD RUBBER COMPOSITION AND TIRE	FURUKAWA, HIROSHI
<u>06496913</u>	Not Issued	166	05/23/1983	COMPOSITION FOR TREAD RUBBER OF TIRES	FURUKAWA, HIROSHI
<u>06503737</u>	Not Issued	161	06/13/1983	CONJUGATED DIENE RUBBER COMPOSITION	FURUKAWA, HIROSHI
<u>06525698</u>	4482678	150	08/23/1983	DIENE RUBBER COMPOSITION AND TIRE USING IT IN TREAD	FURUKAWA, HIROSHI
<u>06576799</u>	4521587	150	02/06/1984	COMPOSITION FOR TREAD RUBBER OF TIRES	FURUKAWA, HIROSHI
<u>06578567</u>	Not Issued	161	02/09/1984	CURRENT-CONDUCTIVE COIL AND METHOD FOR MANUFACTURING THE SAME	FURUKAWA, HIROSHI
<u>06610045</u>	4507512	150	05/14/1984	PROCESS FOR HYDRATION OF OLEFINS	FURUKAWA, HIROSHI
<u>06704453</u>	Not Issued	166	02/22/1985	ELASTOMERIC COPOLYMER OF AROMATIC VINYL COMPOUNDS AND BUTADIENE	FURUKAWA, HIROSHI
<u>06817949</u>	4737535	150	12/17/1985	RUBBER COMPOSITION FOR TIRE TREAD	FURUKAWA, HIROSHI
<u>06947896</u>	4730901	150	12/30/1986	LENS BARREL WITH INTERNAL MOTOR FOCUSING	FURUKAWA, HIROSHI
<u>07005400</u>	4743652	150	02/02/1987	ELASTOMERIC COPOLYMER OF AROMATIC VINYL	FURUKAWA, HIROSHI

				COMPOUNDS AND BUTADIENE	
<u>07074154</u>	4771948	150	07/16/1987	COMBINATION OF A FUEL INJECTION VALVE AND A NOZZLE	FURUKAWA, HIROSHI
<u>07136732</u>	Not Issued	166	12/22/1987	CONNECTOR FOR A CAMERA	FURUKAWA, HIROSHI
<u>07138968</u>	4844586	150	12/29/1987	ADJUSTMENT APPARATUS FOR A LENS BARREL WITH BUILT-IN MOTOR	FURUKAWA, HIROSHI
<u>07167710</u>	4911533	150	03/14/1988	LENS BARREL	FURUKAWA, HIROSHI
<u>07203855</u>	4808957	150	06/08/1988	MAGNETIC SHIELD APPARATUS	FURUKAWA, HIROSHI
<u>07221614</u>	4970558	150	07/20/1988	CONNECTOR FOR A CAMERA	FURUKAWA, HIROSHI
<u>07258178</u>	5028849	150	10/14/1988	DEVICE FOR MEASURING CONVERGENCE OF COLOR CATHODE RAY TUBE	FURUKAWA, HIROSHI
<u>07268448</u>	4898796	250	11/08/1988	LEAD-ACID STORAGE BATTERY	FURUKAWA, HIROSHI
<u>07271363</u>	4853725	150	11/14/1988	CONNECTOR FOR A CAMERA	FURUKAWA, HIROSHI
<u>07274577</u>	4899110	250	11/22/1988	MAGNETIC RESONANCE IMAGING APPARATUS WITH STABILIZED MAGNETIC FIELD	FURUKAWA, HIROSHI
<u>07362368</u>	4979479	150	06/05/1989	FUEL INJECTOR AND MOUNTING STRUCTURE THEREOF	FURUKAWA, HIROSHI
<u>07543971</u>	5028775	150	06/26/1990	OPTICAL TIME DOMAIN REFLECTOMETER USING OPTICAL ELEMENT WITH THREE CONTROL MODES OF OSCILLATION, ATTENUATION AND AMPLIFICATION	FURUKAWA, HIROSHI
<u>07550447</u>	Not Issued	166	07/10/1990	LIGHT MEASUREMENT DEVICE	FURUKAWA, HIROSHI
<u>07550636</u>	5122651	150	07/10/1990	DEVICE FOR MEASURING LUMINANCE OF FLOURESCENT SCREEN OF CATHODE RAY TUBE	FURUKAWA, HIROSHI
<u>07671574</u>	5149831	150	03/19/1991	PROCESS FOR PRODUCING METHYLNORBORNENE	FURUKAWA, HIROSHI

				DICARBOXYLIC ACID ANHYDRIDE	
<a href="#"><u>07819315</u></a>	<a href="#"><u>5198554</u></a>	150	01/09/1992	5-(2,4-DIOXOTETRAHYDRO-3-FURANYLMETHYL) NORBORNANE-2,3-DICARBOXYLIC ACID ANHYDRIDE AND PROCESS FOR PRODUCTION THEREOF	FURUKAWA, HIROSHI
<a href="#"><u>08012157</u></a>	<a href="#"><u>5352545</u></a>	250	01/27/1993	BATTERY CONTAINING FOAM POLYURETHANE RESIN AND METHOD OF MAKING	FURUKAWA, HIROSHI
<a href="#"><u>08016351</u></a>	Not Issued	161	02/11/1993	ACID ANHYDRIDE AND PRODUCTION THEREOF	FURUKAWA, HIROSHI
<a href="#"><u>08022790</u></a>	<a href="#"><u>5327210</u></a>	150	02/23/1993	LIGHT MEASUREMENT DEVICE	FURUKAWA, HIROSHI
<a href="#"><u>08026740</u></a>	Not Issued	161	03/05/1993	NETWORK MANAGEMENT METHOD AND NETWORK SYSTEM	FURUKAWA, HIROSHI
<a href="#"><u>08046942</u></a>	<a href="#"><u>5845078</u></a>	150	04/16/1993	NETWORK INTEGRATED CONSTRUCTION SYSTEM, METHOD OF INSTALLING NETWORK CONNECTION MACHINES, AND METHOD OF SETTING NETWORK PARAMETERS	FURUKAWA, HIROSHI
<a href="#"><u>08069950</u></a>	Not Issued	169	05/28/1993	ACID ANHYDRIDE AND PRODUCTION THEREOF	FURUKAWA, HIROSHI
<a href="#"><u>08088431</u></a>	<a href="#"><u>5442899</u></a>	150	07/07/1993	BAND CHARGING APPARATUS FOR PACKING MACHINE	FURUKAWA, HIROSHI
<a href="#"><u>08115856</u></a>	Not Issued	166	09/02/1993	MAGNETIC RESONANCE IMAGING APPARATUS	FURUKAWA, HIROSHI

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Application#	Patent#	Status	Date Filed	Title	Inventor Name
<a href="#"><u>10500701</u></a>	Not Issued	030	07/02/2004	LOW MOLECULAR WEIGHT POLYPHENYLENE ETHER	OTA, NOBUYUKI
<a href="#"><u>10924507</u></a>	Not Issued	030	08/24/2004	TRANSISTOR CIRCUIT AND BOOSTER CIRCUIT	OTAKA, NOBUYUKI
<a href="#"><u>06123508</u></a>	RE30659	150	02/22/1980	PEN POINTS FOR WRITING INSTRUMENTS	OTAKE, NOBUYUKI
<a href="#"><u>07321879</u></a>	Not Issued	166	03/10/1989	PROCESS FOR THE PREPARATION OF MICROSFERICAL SINTERED BODIES OF HYDROXYAPATITE AND A CHROMATOGRAPHIC PACKING MATERIAL COMPRISING THE MICROSFERICAL SINTERED BODIES OF HYDROXYAPATITE	OTAKI, NOBUYUKI
<a href="#"><u>07704732</u></a>	5108956	150	05/20/1991	PROCESS FOR THE PREPARATION OF MICROSFERICAL SINTERED BODIES OF HYDROXYAPATITE AND A CHROMATOGRAPHIC PACKING MATERIAL COMPRISING THE MICROSFERICAL SINTERED BODIES OF HYDROXYAPATITE	OTAKI, NOBUYUKI
<a href="#"><u>07774512</u></a>	5205928	150	10/08/1991	PROCESS FOR THE PREPARATION OF MICROSFERICAL SINTERED BODIES OF HYDROXYAPATITE AND A CHROMATOGRAPHIC PACKING MATERIAL	OTAKI, NOBUYUKI

				COMPRISING THE MICROSFERICAL SINTERED BODIES OF HYDROXYAPATITE	
<u>08204414</u>	Not Issued	166	03/15/1994	STATIONARY PHASE MATERIAL FOR CHROMATOGRAPHY	OTAKI, NOBUYUKI
<u>08626267</u>	<u>5728463</u>	150	04/01/1996	STATIONARY PHASE MATERIAL FOR CHROMATOGRAPHY	OTAKI, NOBUYUKI
<u>09194216</u>	<u>6437023</u>	150	11/20/1998	LIQUID PRESSURE TRANSFER INK, LIQUID PRESSURE TRANSFER FILM, LIQUID PRESSURE TRANSFER PRODUCT AND LIQUID PRESSURE TRANSFER METHOD	OTAKI, NOBUYUKI
<u>09202588</u>	<u>6551392</u>	150	12/17/1998	LIQUID PRESSURE TRANSFER INK, LIQUID PRESSURE TRANSFER FILM, LIQUID PRESSURE TRANSFER ARTICLE AND LIQUID PRESSURE TRANSFER METHOD	OTAKI, NOBUYUKI
<u>09214468</u>	Not Issued	161	01/20/1999	LIQUID PRESSURE TRANSFER INK, LIQUID PRESSURE TRANSFER FILM, LIQUID PRESSURE TRANSFER PRODUCT AND LIQUID PRESSURE TRANSFER METHOD	OTAKI, NOBUYUKI
<u>09509248</u>	<u>6497779</u>	150	03/23/2000	HYDRAULIC TRANSFER METHOD AND DEVICE AND HYDRAULIC-TRANSFER ARTICLE	OTAKI, NOBUYUKI
<u>09737514</u>	<u>6554940</u>	150	12/15/2000	METHOD OF TRANSFERRING A PRINT PATTERN COMPOSED OF A FLUOROPOLYMER RESIN AND AN INORGANIC PIGMENT ONTO AN OBJECTIVE BODY USING LIQUID PRESSURE	OTAKI, NOBUYUKI
<u>10372152</u>	<u>6852394</u>	150	02/21/2003	LIQUID PRESSURE PATTERN-TRANSFERRING INK, A LIQUID PRESSURE PATTERN-TRANSFERRING FILM, A	OTAKI, NOBUYUKI

				LIQUID PRESSURE PATTERN- TRANSFERRED ARTICLE AND A METHOD OF TRANSFERRING A PRINT PATTERN ON AN OBJECTIVE BODY UNDER A LIQUID PRESSURE	
07981473	Not Issued	161	11/25/1992	MEASURING DEVICE	OTAWA, NOBUYUKI

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